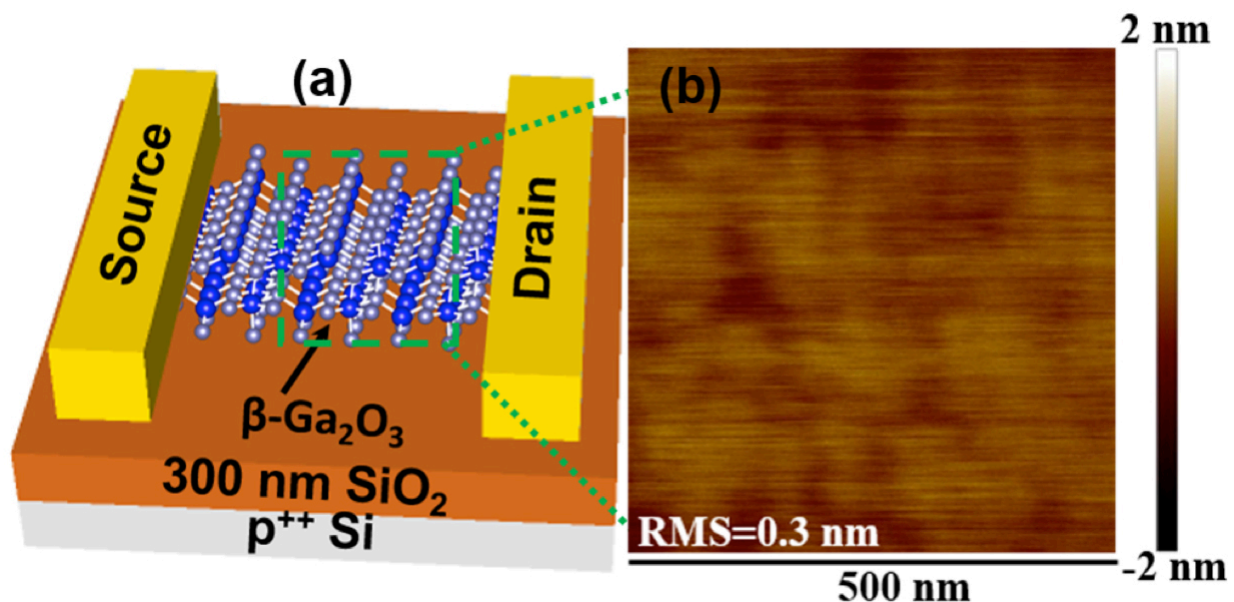


# Semiconductor eyed for next-generation 'power electronics'

January 10 2017, by Emil Venere



The schematic at left shows the design for an experimental transistor made of a semiconductor called beta gallium oxide, which could bring new ultra-efficient switches for applications such as the power grid, military ships and aircraft. At right is an atomic force microscope image of the semiconductor. Credit: Purdue University image/Peide Ye

Researchers have demonstrated the high-performance potential of an experimental transistor made of a semiconductor called beta gallium oxide, which could bring new ultra-efficient switches for applications such as the power grid, military ships and aircraft.

The semiconductor is promising for next-generation "power electronics," or devices needed to control the flow of electrical energy in circuits. Such a technology could help to reduce global energy use and [greenhouse gas emissions](#) by replacing less efficient and bulky power electronics switches now in use.

The transistor, called a gallium oxide on insulator [field effect transistor](#), or GOOI, is especially promising because it possesses an "ultra-wide bandgap," a trait needed for switches in high-voltage applications.

Compared to other semiconductors thought to be promising for the transistors, devices made from beta gallium oxide have a higher "breakdown voltage," or the voltage at which the device fails, said Peide Ye, Purdue University's Richard J. and Mary Jo Schwartz Professor of Electrical and Computer Engineering.

Findings are detailed in a research paper published this month in *IEEE Electron Device Letters*. Graduate student Hong Zhou performed much of the research.

The team also developed a new low-cost method using adhesive tape to peel off layers of the semiconductor from a single crystal, representing a far less expensive alternative to a laboratory technique called epitaxy. The market price for a 1-centimeter-by-1.5-centimeter piece of beta gallium oxide produced using epitaxy is about \$6,000. In comparison, the "Scotch-tape" approach costs pennies and it can be used to cut films of the beta [gallium oxide](#) material into belts or "nano-membranes," which can then be transferred to a conventional silicon disc and manufactured into devices, Ye said.

The technique was found to yield extremely smooth films, having a surface roughness of 0.3 nanometers, which is another factor that bodes well for its use in electronic devices, said Ye, who is affiliated with the

NEPTUNE Center for Power and Energy Research, funded by the U.S. Office of Naval Research and based at Purdue's Discovery Park. Related research was supported by the center.

The Purdue team achieved electrical currents 10 to 100 times greater than other research groups working with the semiconductor, Ye said.

One drawback to the material is that it possesses poor thermal properties. To help solve the problem, future research may include work to attach the material to a substrate of diamond or aluminum nitride.

**More information:** High Performance Depletion/Enhancement-Mode  $\beta$ -Ga<sub>2</sub>O<sub>3</sub> on Insulator (GOOI) Field-effect Transistors with Record Drain Currents of 600/450 mA/mm, *IEEE Electron Device Letters*, 2017.

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